

Amendments to the Specification:

Please replace the sentence beginning at page 5, line 22 with the following amended sentence:

Meanwhile, for comparison with this, a magnetic head was formed similarly, where when the magnetic multilayer film 2 was formed, the thickness of ~~FeTaSiN~~ FeTaN films 8 as the magnetic films was made constant at 0.5 μm and the thickness of the SiO_2 films 9 as the non-magnetic layers was set at 10 nm as shown in Fig. 10, so that the overall film thickness of the laminated film was about 6 μm .